

The AT&T Individualized Language Learning Center



If you're interested in studying a language and need a flexible schedule and individualized attention, the AT&T Individualized Language Learning Center (ILLC) located in Hagerty Hall 120 is the place for you. Our students set their own deadlines, make their own appointments with instructors, and they decide what they want to accomplish each day as they learn a foreign language.

The AT&T Individualized Language Learning Center houses eight individualized instruction language programs. OSU was a pioneer in the development of individualized instruction and maintains the longest running program in the country. The Center offers eight different language programs: Arabic, Chinese, French, German, Japanese, Korean, Portuguese and Russian. The ILLC's self-directed language courses are equivalent in content and in credit hours to the classroom.



Students receive individual attention and one-on-one instruction.

Based on more than thirty years of experience with individualized instruction, we have observed that students who succeed in the ILLC are independent and well organized, like one-on-one learning, and have experience in another language. In addition, they do not procrastinate and they know how to manage their time.

Individualized instruction allows students to be in charge of their own learning in a variety of ways: scheduling required and optional appointments, determining the number of credit hours to take for a given quarter, and deciding when to take tests and quizzes. The Center's evening and weekend hours allow students to complete coursework at times convenient to them.



Both introductory and advanced courses are offered.

Courses Offered in Individualized Instruction:

Arabic 101-104; 151; 205
Chinese 101-104; 211, 311, 511
French 101-201
German 101-104
Japanese 101-104
Korean 101-104
Portuguese 101-104
Russian 101-104; 405, 407, 580-582, 571-573

Please visit us at <http://wmcc.osu.edu/IILC.htm>



IILC students benefit from available online multimedia materials.